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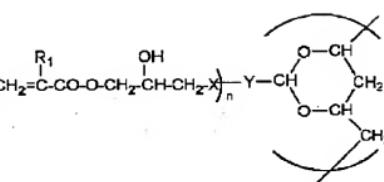
INT.CL. : G03F 7/033 G03F 7/027 // C08F 18/08 R₁=Me, H

n=1, 2

TITLE : PHOTOSENSITIVE RESIN AND
 PHOTOSENSITIVE RESIN
 COMPOSITION



Y=芳香族環または単結合



ABSTRACT : PROBLEM TO BE SOLVED: To easily obtain a photosensitive resin having wide aptitude and superior preservation stability and high sensitivity and high resolution.

SOLUTION: This photosensitive resin is a photopolymerizable type resin, having a polyvinyl acetate saponified product as a main structural chain comprising the structural units each represented by general formula I. The photosensitive resin composition is prepared by using this photosensitive resin.

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